

Intensity-dependent effects in ATF2 and ILC

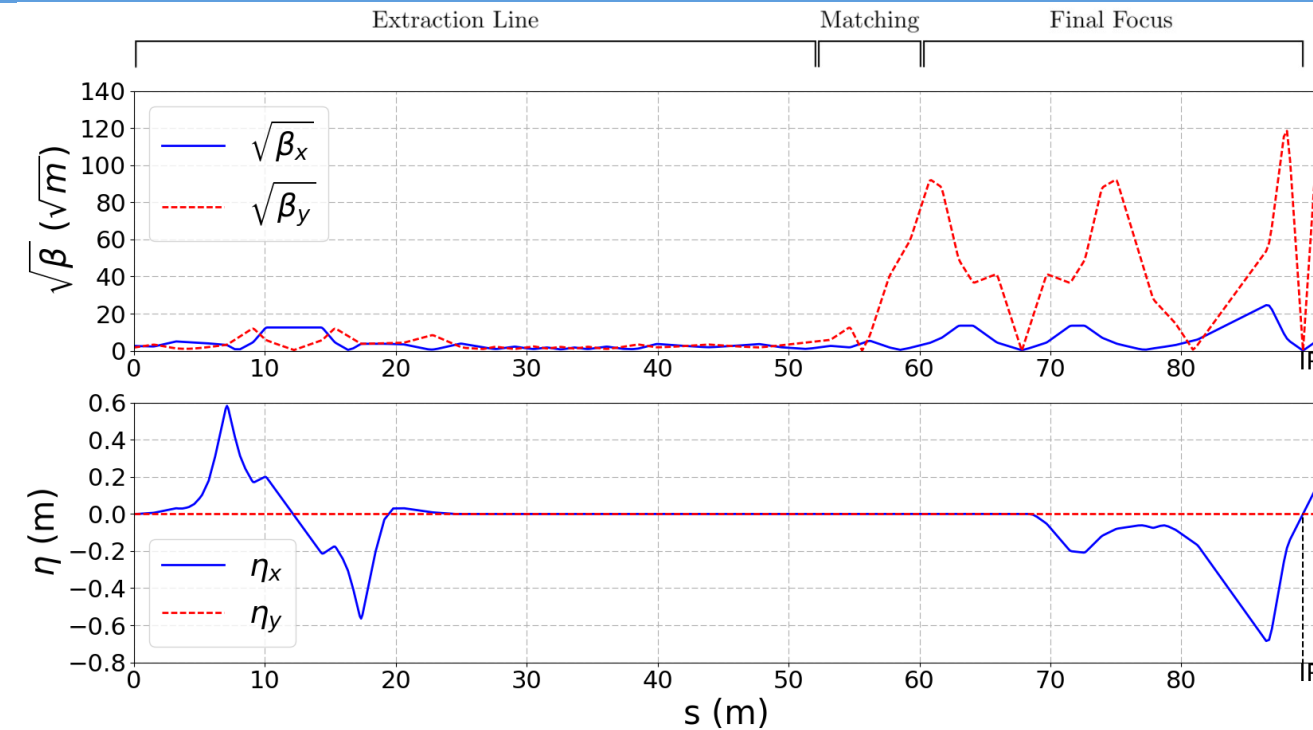
P. Korysko
University of Oxford
CERN



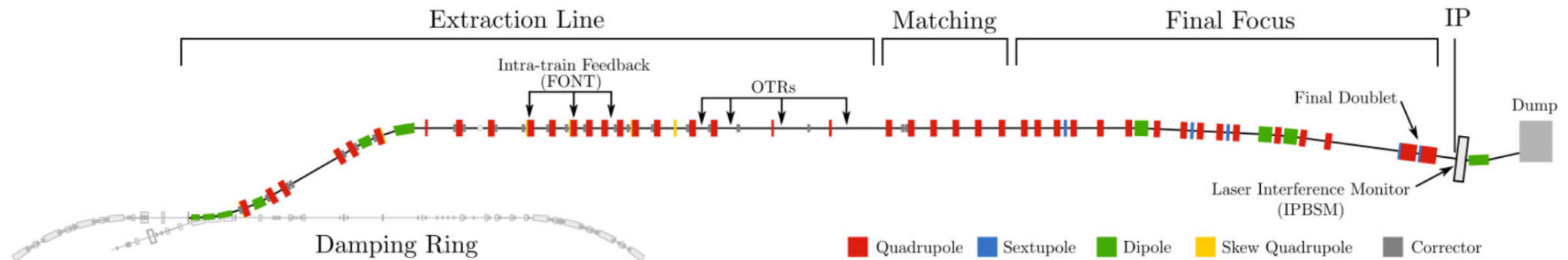
Outline

- Intensity-dependent effects in ATF2.
Simulations of the impact of short-range wakefields in ATF2 with static and dynamic imperfections and with corrections.
- Intensity-dependent effects in ILC.
Simulations of the impact of short-range and long-range wakefields in the ILC BDS with static imperfections and with corrections.

ATF2 Parameters and Optics



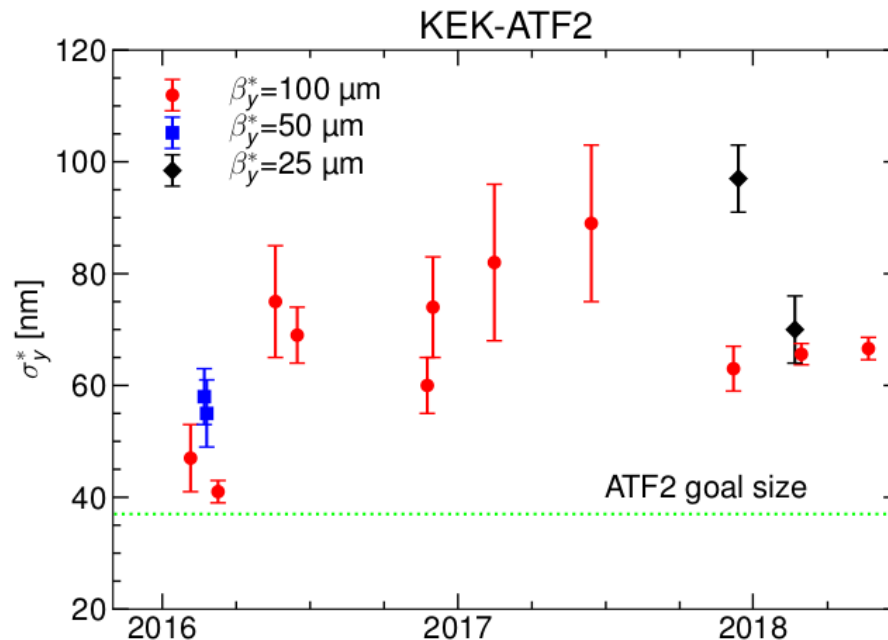
Parameter	Symbol	Value
Length of ATF2	L	90 m
Beam energy	E	1.3 GeV
Nominal bunch population	N_e	$1.0 \times 10^{10} e^-$
Nominal beam sizes at IP	σ_x^*/σ_y^*	8.9 μm /37 nm
Bunch length	σ_z	7 mm



Goals of ATF2

Goal 1: Obtain a small beam size at the IP ($\sigma_y^* = 37$ nm). Demonstrate the performance of the Final Focus System based on local chromaticity correction.

Goal 2: Control the beam position. Demonstrate the performance of the beam orbit's stabilisation with a nanometer precision at the IP.



Minimum of $\sigma_y^* = 42$ nm measured in 2016.

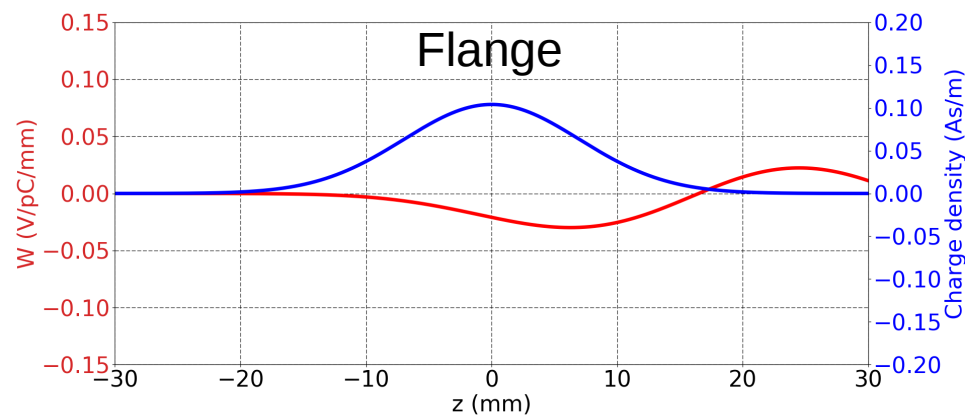
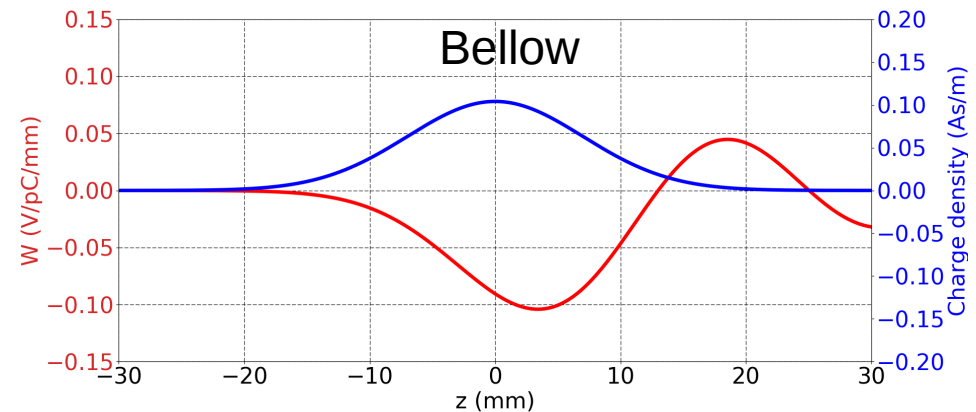
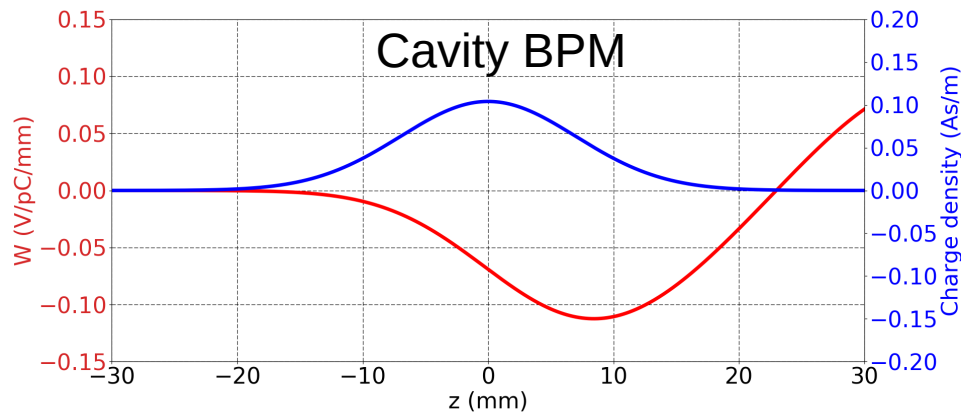
All these measurements were done at around **10% of the nominal beam intensity** (1.0×10^9 e⁻).

Intensity-dependent effects in ATF2

Simulation conditions

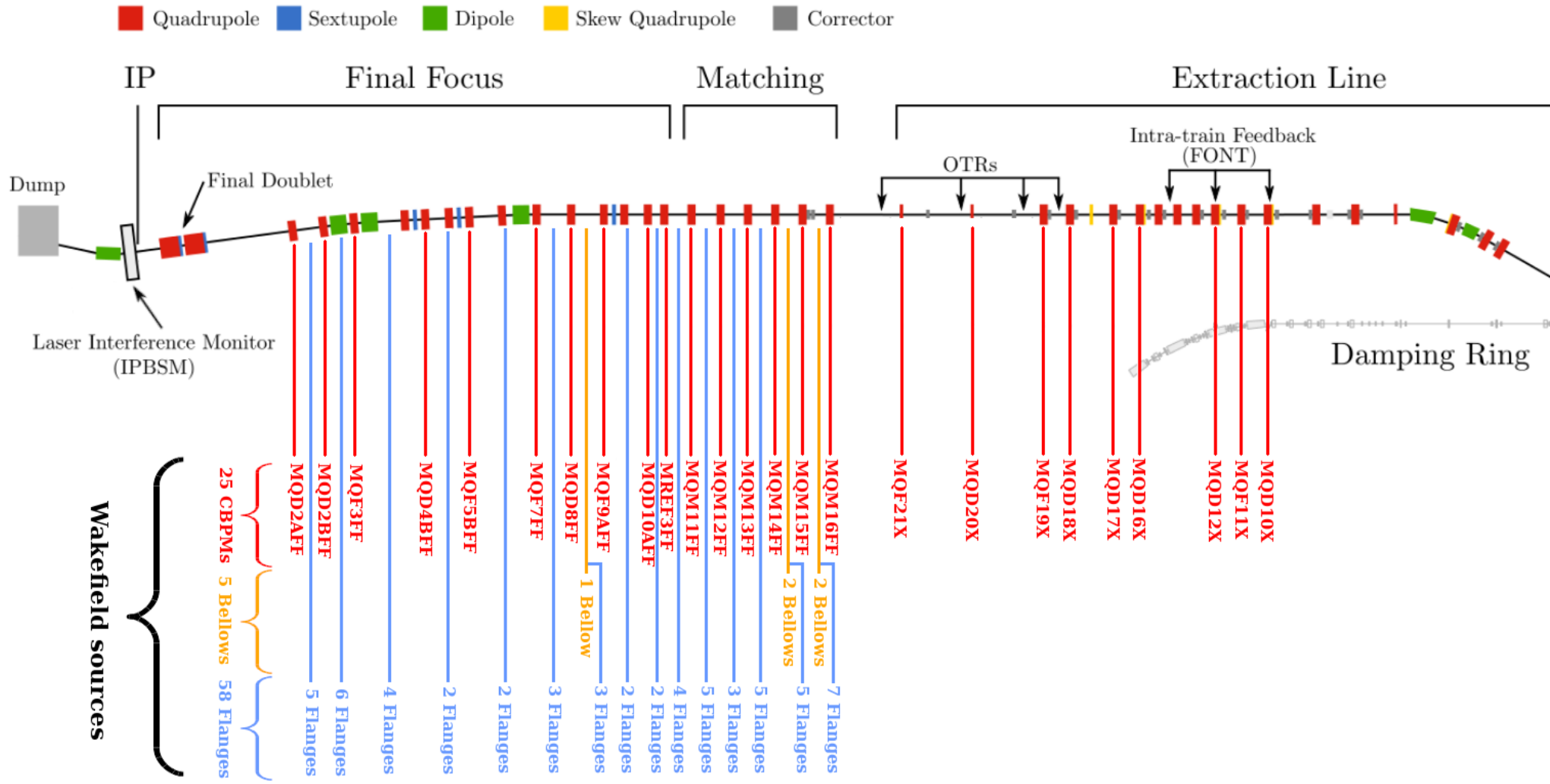
Wakefields:

- Simulations were done with PLACET, a code developed at CERN, which simulates the dynamics of a beam in the main accelerating or decelerating part of a linac in the presence of wakefields.
- Wakefield sources: Cavity BPMs, bellows and flanges (wakepotentials calculated with Gdfdl).



Simulation conditions

Positions of wakefield sources



Simulation conditions

Static imperfections:

- Misalignment of Quadrupoles, CavBPMs, Sextupoles of 100 μm RMS.
- Strength error of Quadrupoles and Sextupoles of 1×10^{-3} RMS.
- Roll error of Quadrupoles, CavBPMs and Sextupoles of 200 μrad RMS.
- 100 random machines.

Dynamic imperfections:

- 200 pulses: initial position jitter of $[0.1\sigma_y - 0.5\sigma_y]$ RMS or angle jitter of $[0.1\sigma_{y'} - 0.5\sigma_{y'}]$ RMS.
(With $\sigma_{y'}$ the angular divergence: $\sigma_{y'} = \sqrt{\epsilon_y / \beta_y}$)

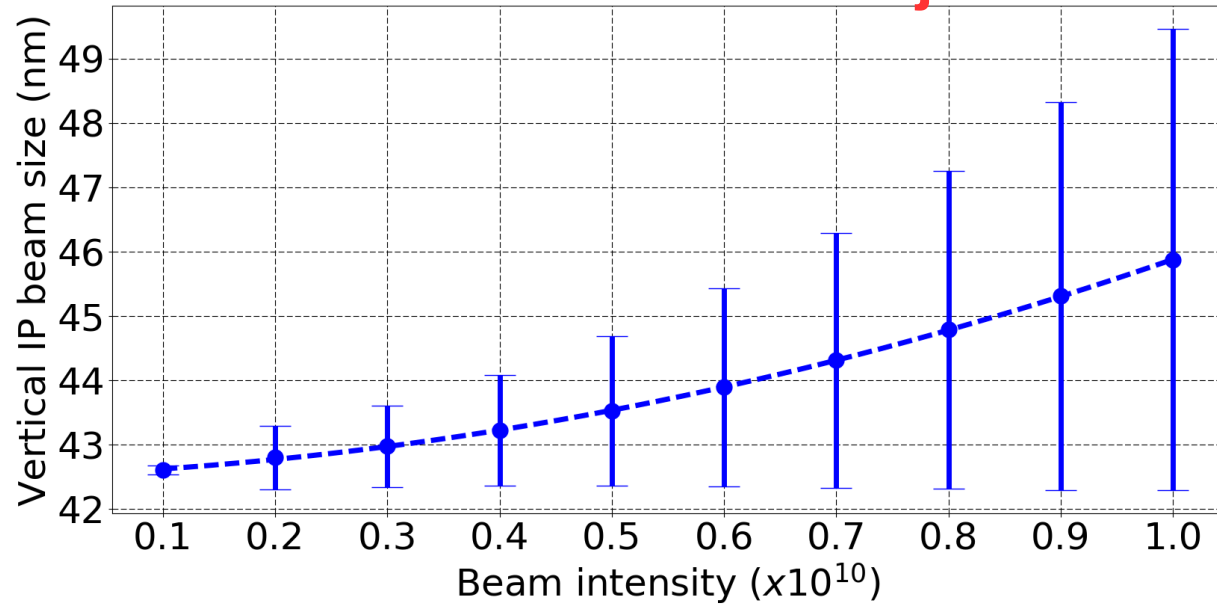
Corrections:

- BBA correction applied: 1to1, DFS, WFS.
- Ideal knobs used to correct the IP distribution:
 $\langle y, x' \rangle$, $\langle y, y' \rangle$, $\langle y, E \rangle$, $\langle y, x'^2 \rangle$, $\langle y, x' * y' \rangle$, $\langle y, x' * E \rangle$.

ATF2 Intensity-dependent effects simulations

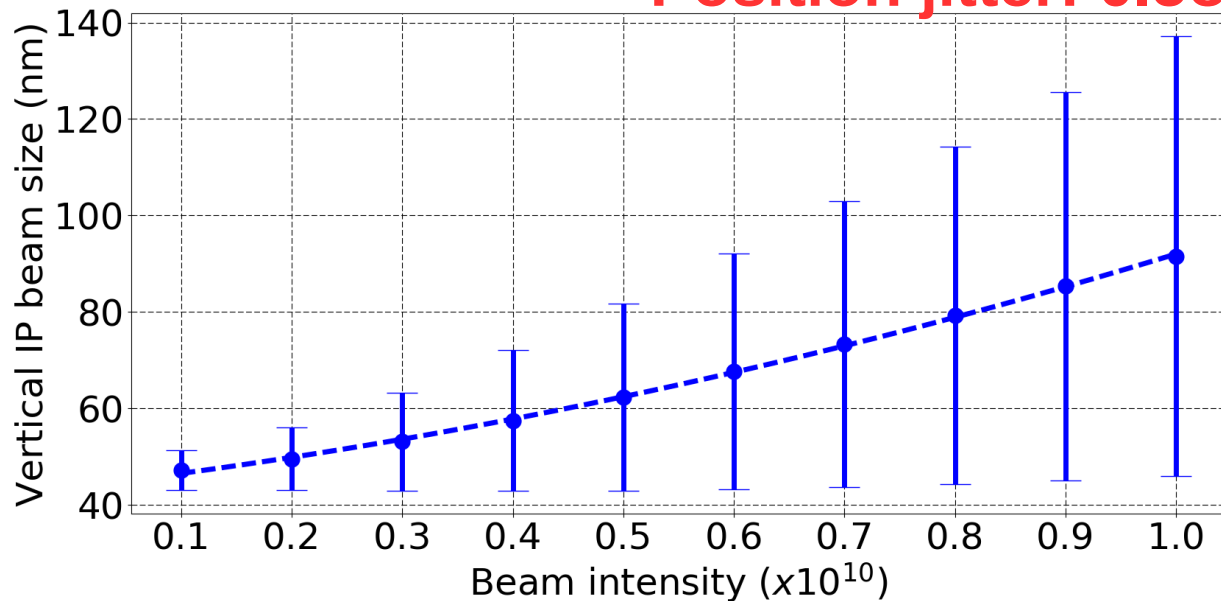
Impact of position jitter

Position jitter: $0.1\sigma_y$



Intensity	Average $\sigma_{y,ip}$	90 th percentile*
N=2.0x10 ⁹	42.79nm	50.56nm
N=10x10 ⁹	45.81nm	55.98nm

Position jitter: $0.5\sigma_y$

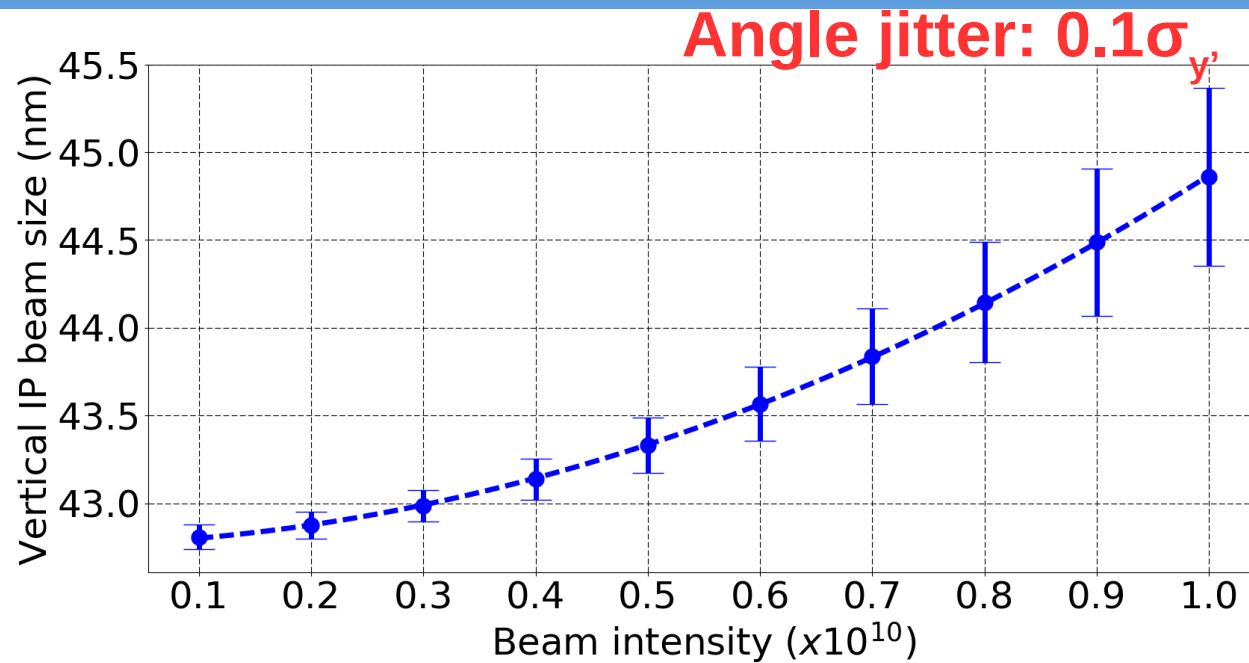


Intensity	Average $\sigma_{y,ip}$	90 th percentile*
N=1.0x10 ⁹	46.69nm	57.18nm
N=10x10 ⁹	91.42nm	159.93nm

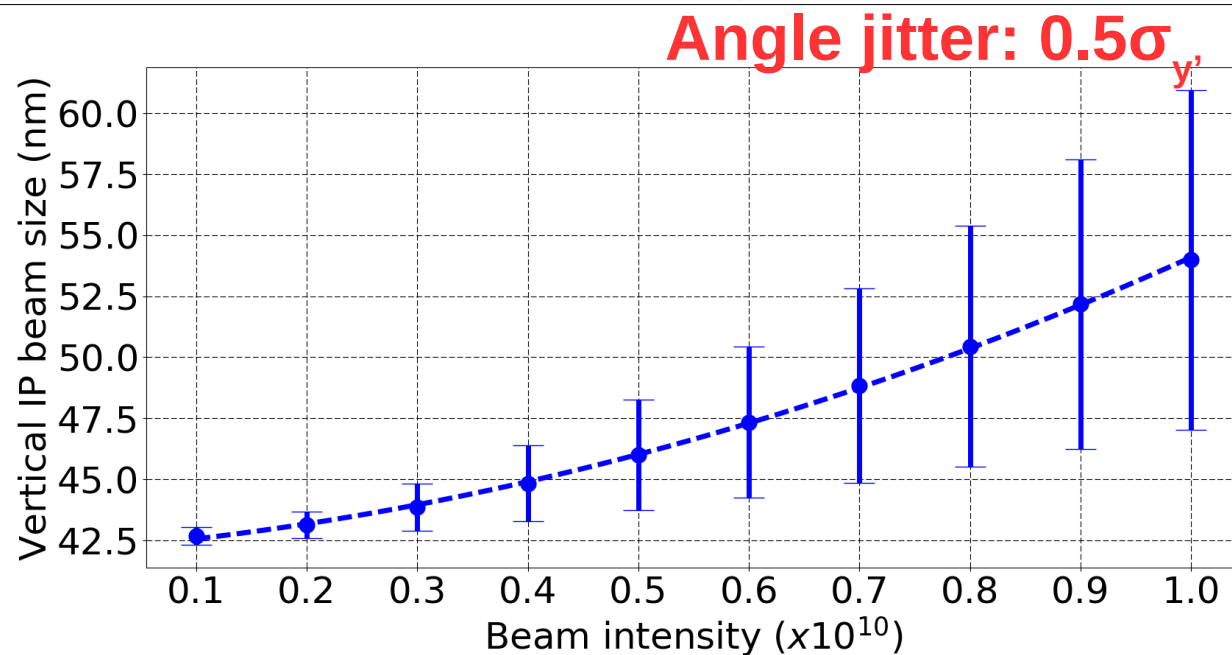
* 90% of the beam sizes are smaller than this value

ATF2 Intensity-dependent effects simulations

Impact of angle jitter



Intensity	Average $\sigma_{y,ip}$	90 th percentile*
N=2.0x10 ⁹	42.56nm	49.89nm
N=10x10 ⁹	44.63nm	52.85nm

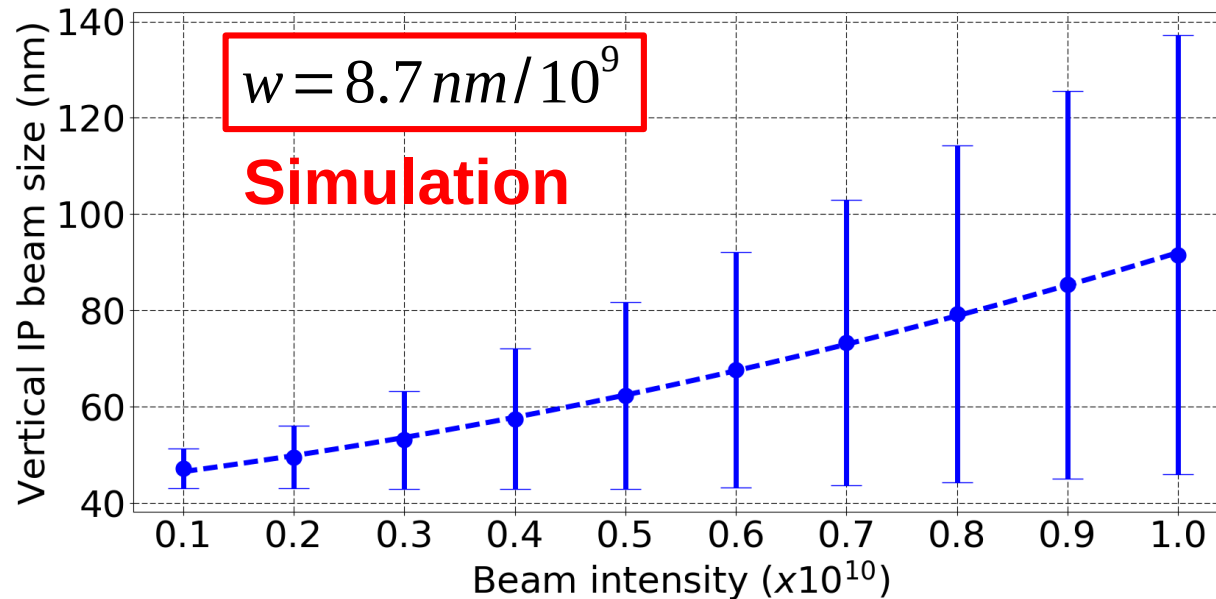


Intensity	Average $\sigma_{y,ip}$	90 th percentile*
N=1.0x10 ⁹	42.79nm	51.26nm
N=10x10 ⁹	54.08nm	78.18nm

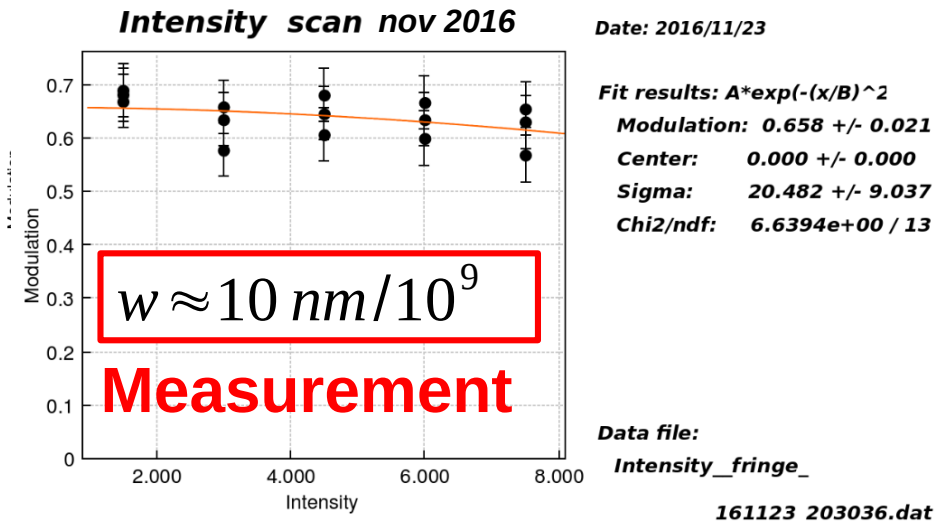
10
* 90% of the beam sizes are smaller than this value

Dynamic effects

Comparison simulation/measurement



Intensity	Average $\sigma_{y,ip}$	90 th percentile*
N=1.0x10 ⁹	46.69nm	57.18nm
N=10x10 ⁹	91.42nm	159.93nm



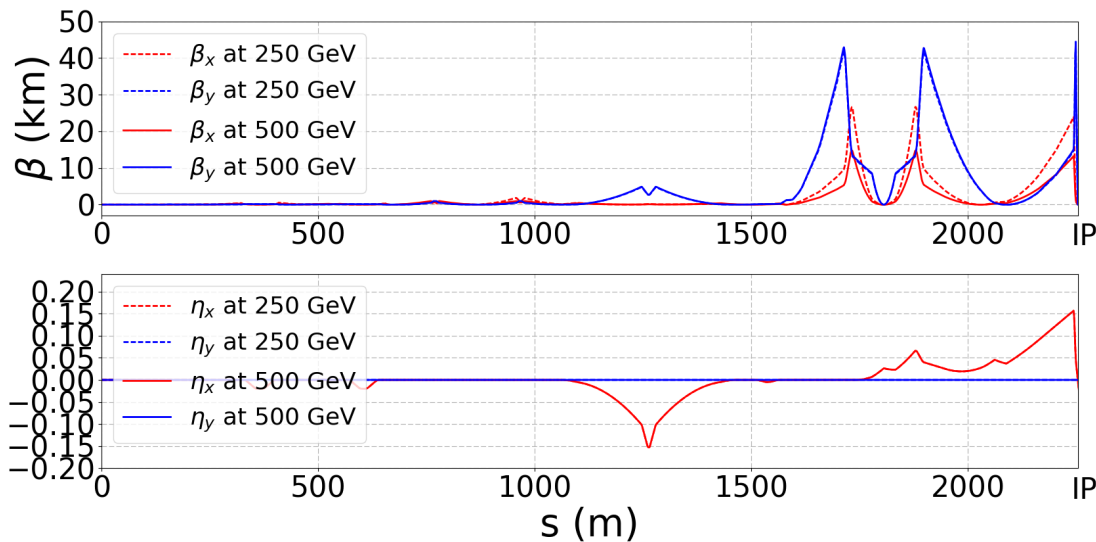
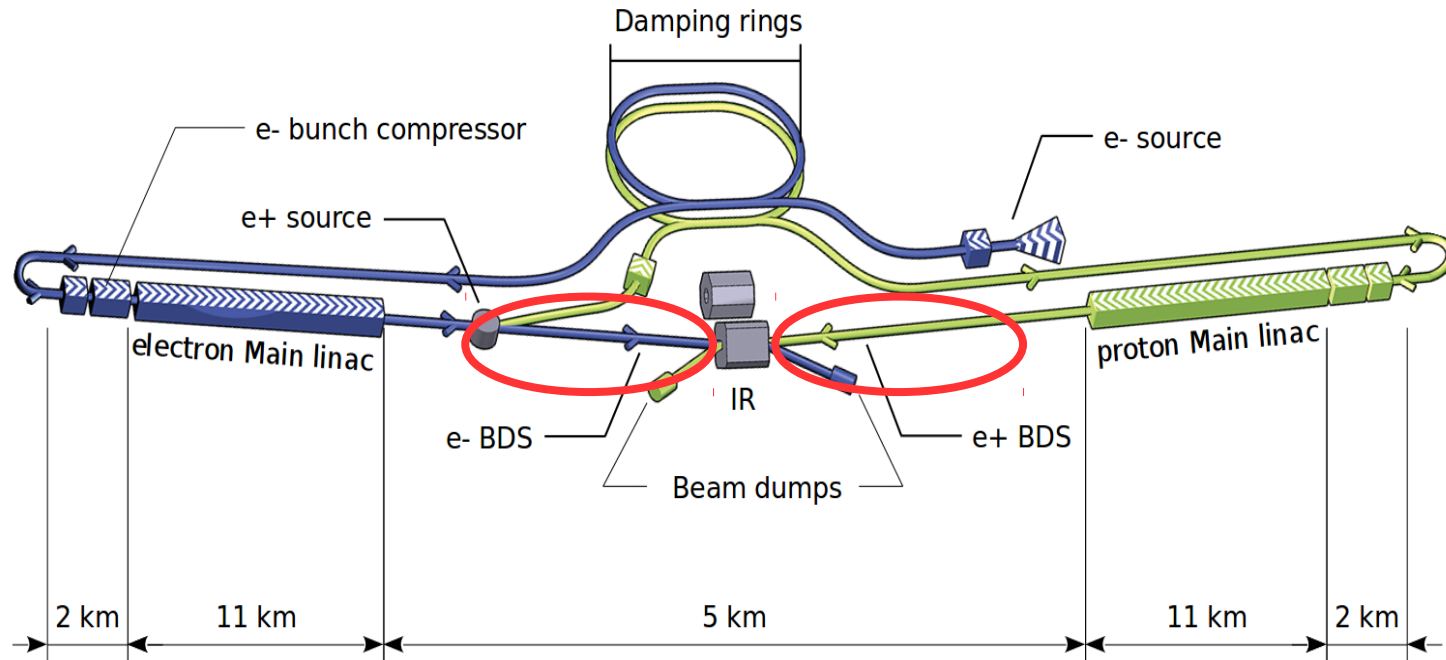
Intensity dependence parameter:

$$w [nm/10^9] = \frac{\sqrt{\sigma_y^2 - \sigma_{y,N=0}^2}}{N}$$

Intensity-dependent effects in ILC BDS

ILC BDS

Parameters and optics



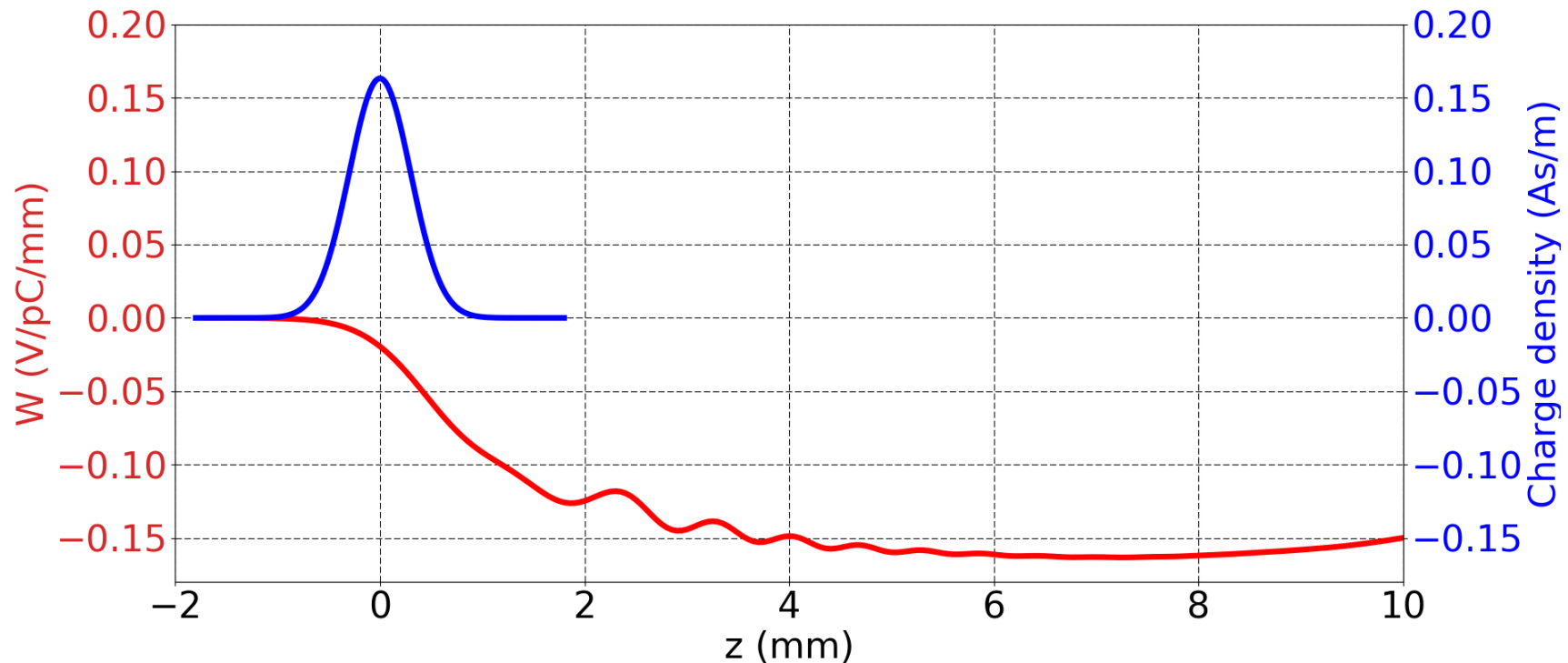
Parameter		Initial	Upgrade
Centre-of-mass energy	E_{CM} [GeV]	250	500
Number of bunches	n_b	1312	1312
Bunch population	$N \times 10^{10}$	2.0	2.0
rms bunch length	σ_z [mm]	0.3	0.3
Bunch separation	Δt_b [ns]	554	554
IP rms beam sizes	σ_x^*/σ_y^* [nm]	729/7.7	474/5.9

Intensity-dependent effects in ILC BDS for a single bunch

Simulation conditions

Wakefields:

- Short-range wakefield sources: Cavity BPMs (masked bellows and flanges).



Intensity-dependent effects in ILC BDS for a single bunch

Simulation conditions

Wakefields:

- Short-range wakefield sources: Cavity BPMs (masked bellows and flanges).

Static imperfections:

- Misalignment of Quadrupoles, CavBPMs, Sextupoles of 50 μm RMS.
- Strength error of Quadrupoles and Sextupoles of 1×10^{-4} RMS.
- Roll error of Quadrupoles, CavBPMs and Sextupoles of 200 μrad RMS.
- 100 random machines.

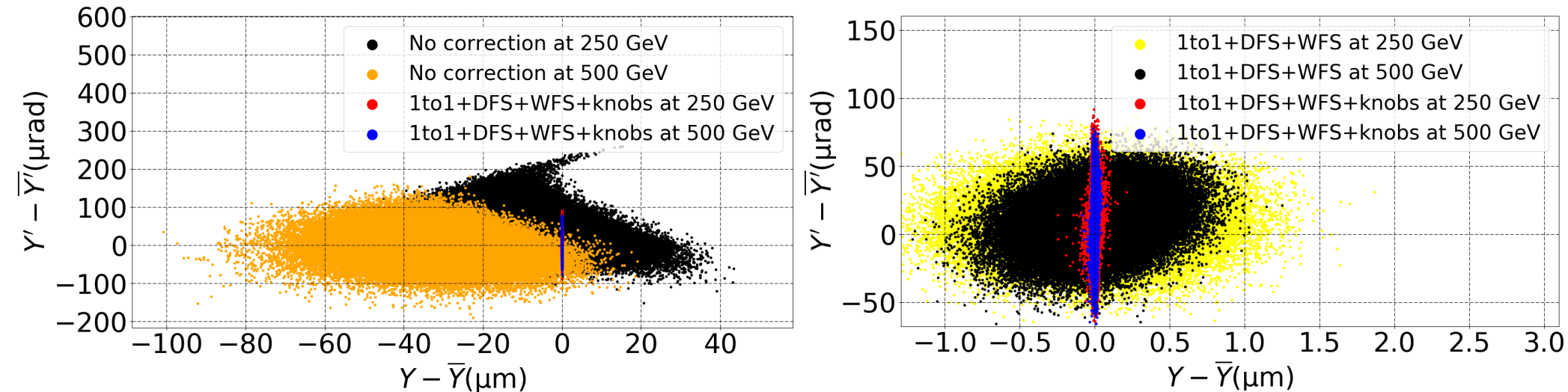
Corrections:

- BBA correction applied: 1to1, DFS, WFS.
- Ideal knobs used to correct the IP distribution:
 $\langle y, x' \rangle$, $\langle y, y' \rangle$, $\langle y, E \rangle$, $\langle y, x'^2 \rangle$, $\langle y, x' * y' \rangle$, $\langle y, x' * E \rangle$.

Intensity-dependent effects in ILC BDS for a single bunch

Correction impact

For one machine:



For 100 machines:

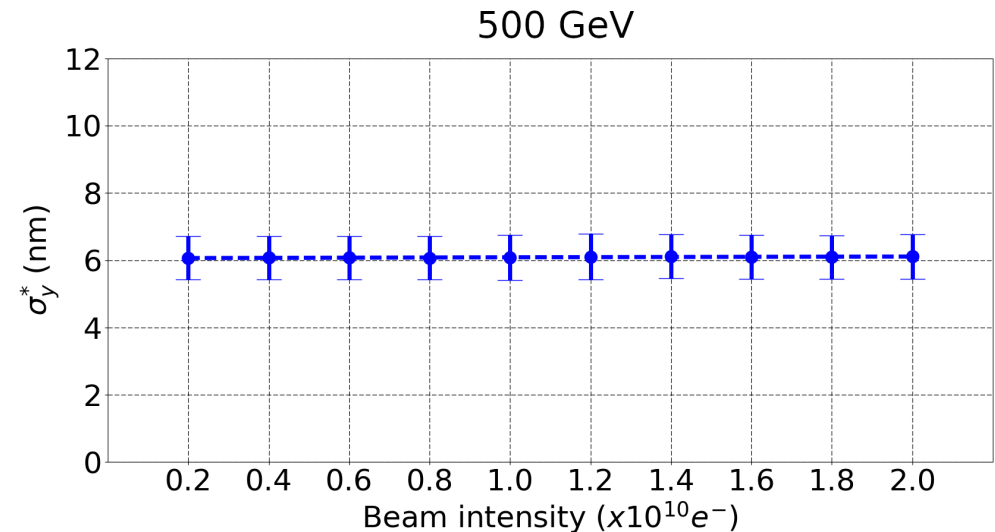
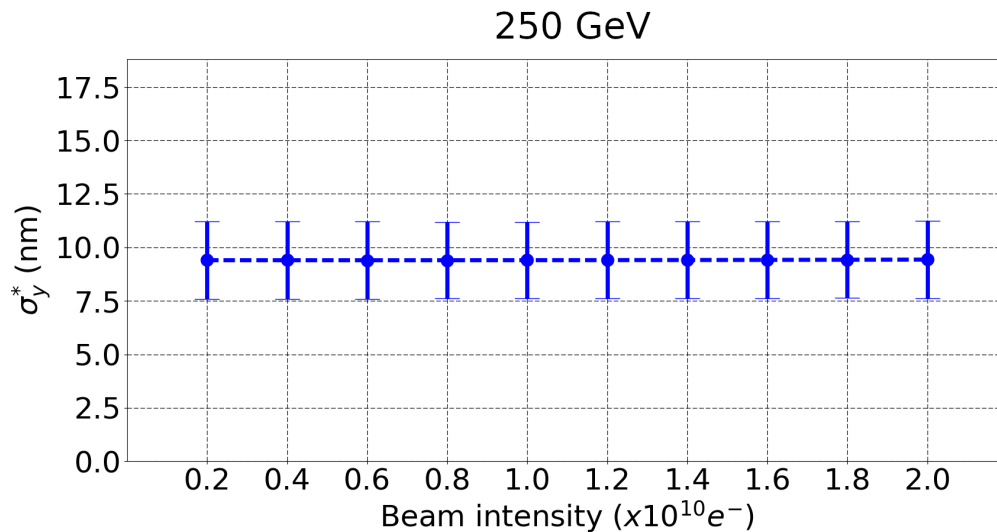
CM energy (GeV)	250		500	
Intensity (e^-)	2.0×10^9	2.0×10^{10}	2.0×10^9	2.0×10^{10}
Correction	Average σ_y^* [nm]		Average σ_y^* [nm]	
No correction	21120	22001	12669	12882
1to1	752	783	451	458
1to1+DFS	590	614	354	367
1to1+DFS+WFS	587	611	352	365
1to1+DFS+WFS+knobs	9.40	9.43	6.07	6.11

For perfect machine: $\sigma_{y,250 \text{ GeV}}^* = 7.7 \text{ nm}$, $\sigma_{y,500 \text{ GeV}}^* = 5.9 \text{ nm}$

Intensity-dependent effects in ILC BDS for a single bunch

Results

CM energy (GeV)	250		500	
Intensity (e^-)	2.0×10^9	2.0×10^{10}	2.0×10^9	2.0×10^{10}
Correction	Average σ_y^* [nm]		Average σ_y^* [nm]	
1to1+DFS+WFS+knobs	9.40	9.43	6.07	6.11



The intensity-dependent effects in the ILC BDS due to short-range wakefields are relatively small if one takes into account the cited imperfections and corrections.

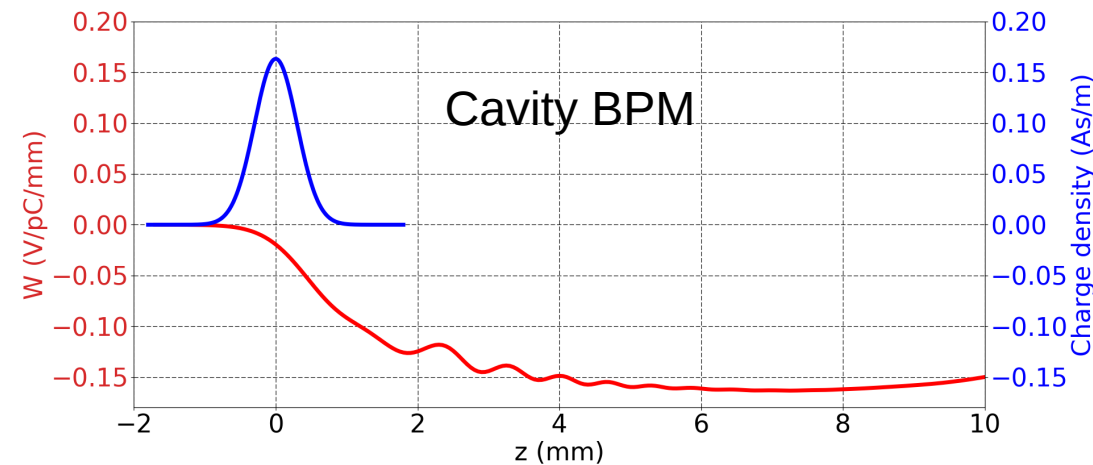
Intensity-dependent effects in ILC BDS for train of bunches

Simulation conditions

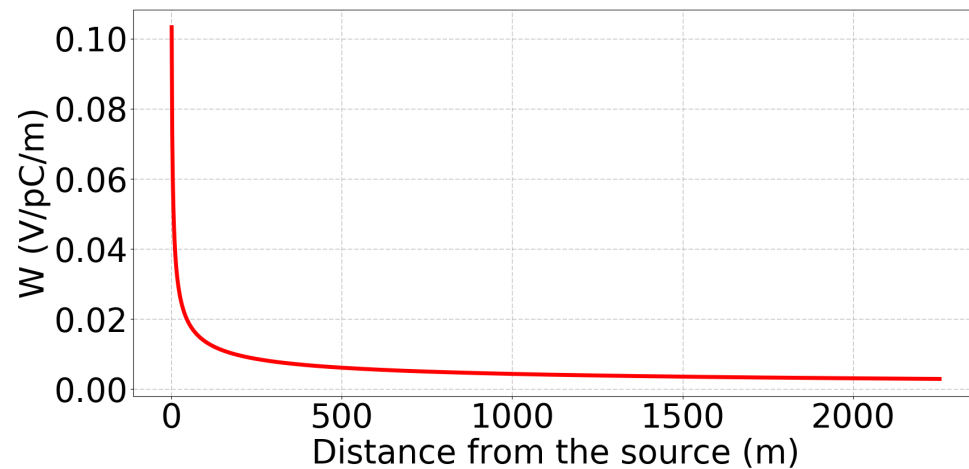
Wakefields:

- Short-range wakefield sources: Cavity BPMs (masked bellows and flanges).
- Long-range wakefield sources: resistive walls.

Short range



Long range



$$W(z) = \frac{c}{\pi b^3} \sqrt{\left(\frac{Z_0}{\sigma_r \pi z}\right) L}$$

Intensity-dependent effects in ILC BDS for train of bunches

Simulation conditions

Wakefields:

- Short-range wakefield sources: Cavity BPMs (masked bellows and flanges).
- Long-range wakefield sources: resistive walls.

No static or dynamic imperfections.

1312 consecutive bunches in a train.

One macroparticle per bunch.

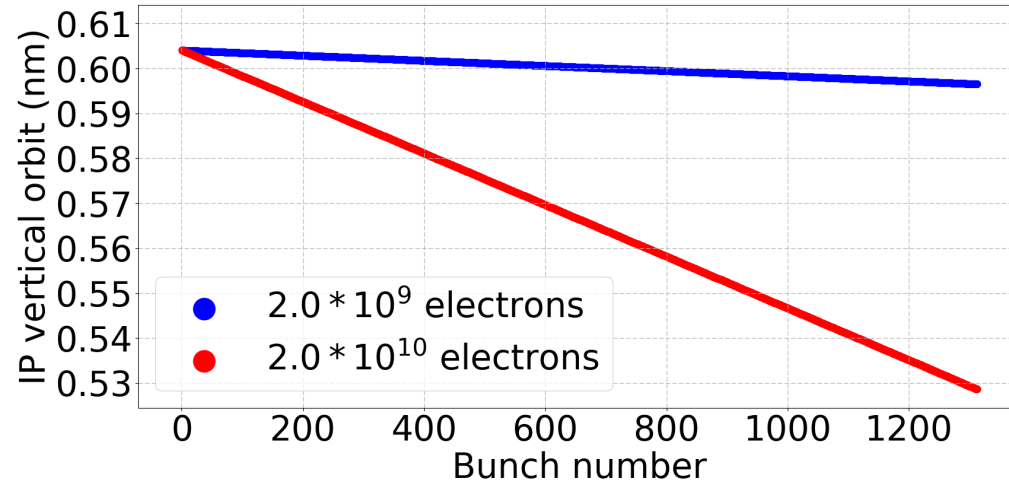
Initial position offset of the train of $[0.1\sigma_y - 1.0\sigma_y]$.

Initial angle offset of the train of $[0.1\sigma_{y'} - 1.0\sigma_{y'}]$.

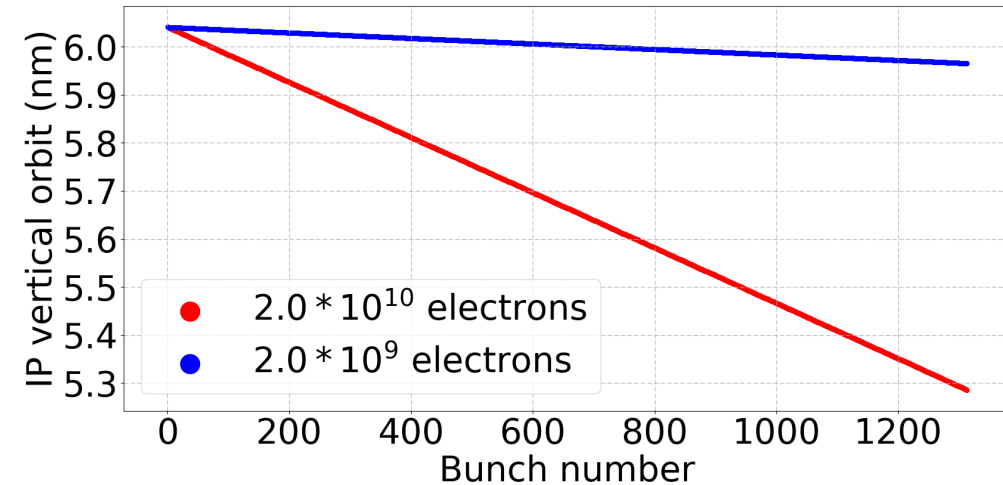
Intensity-dependent effects in ILC BDS for train of bunches

Results for 500 GeV

Initial position offset of $0.1\sigma_y$:



Initial position offset of $1.0\sigma_y$:



Incoming Y	Intensity	Δ_y at IP
$0.1\sigma_y$	$2.0 \times 10^9 e^-$	0.008 nm
$0.1\sigma_y$	$2.0 \times 10^{10} e^-$	0.076 nm
$1.0\sigma_y$	$2.0 \times 10^9 e^-$	0.075 nm
$1.0\sigma_y$	$2.0 \times 10^{10} e^-$	0.755 nm
Incoming Y'	Intensity	Δ_y at IP
$0.1\sigma_{y'}$	$2.0 \times 10^9 e^-$	0.019 nm
$0.1\sigma_{y'}$	$2.0 \times 10^{10} e^-$	0.20 nm
$1.0\sigma_{y'}$	$2.0 \times 10^9 e^-$	0.19 nm
$1.0\sigma_{y'}$	$2.0 \times 10^{10} e^-$	2.03 nm

Intensity-dependent effects in ILC BDS for train of bunches

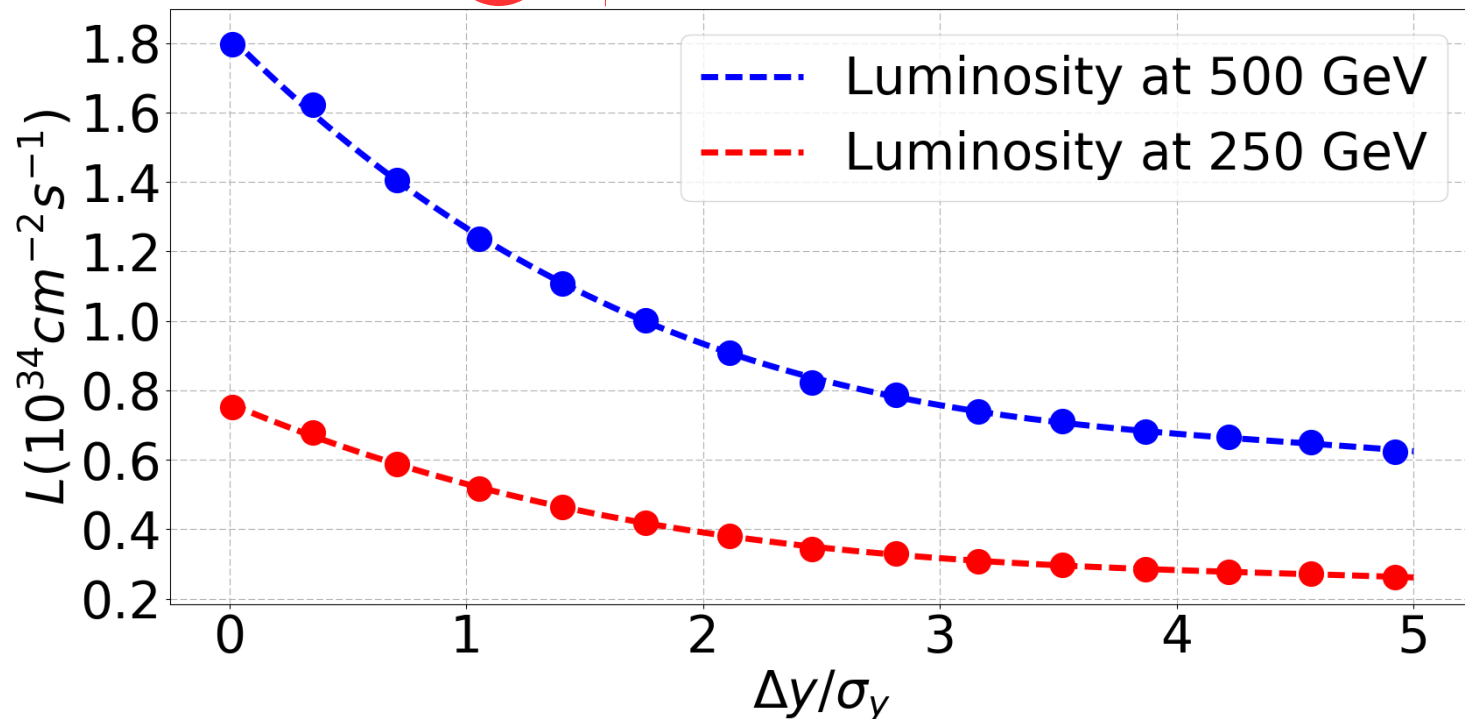
Impact on the luminosity

Incoming Y	Intensity	Δ_y at IP	L / L_0
$0.1\sigma_y$	$2.0 \times 10^9 e^-$	0.008 nm	~ 1.0
$0.1\sigma_y$	$2.0 \times 10^{10} e^-$	0.076 nm	0.998
$1.0\sigma_y$	$2.0 \times 10^9 e^-$	0.075 nm	0.998
$1.0\sigma_y$	$2.0 \times 10^{10} e^-$	0.755 nm	0.964
Incoming Y'	Intensity	Δ_y at IP	L / L_0
$0.1\sigma_{y'}$	$2.0 \times 10^9 e^-$	0.019 nm	~ 1.0
$0.1\sigma_{y'}$	$2.0 \times 10^{10} e^-$	0.20 nm	0.992
$1.0\sigma_{y'}$	$2.0 \times 10^9 e^-$	0.19 nm	0.996
$1.0\sigma_{y'}$	$2.0 \times 10^{10} e^-$	2.03 nm	0.901

Luminosity loss at 500 GeV:

3.6% at $2 \times 10^{10} e^-$ with an incoming position offset of $1.0\sigma_y$

9.9% at $2 \times 10^{10} e^-$ with an incoming angle offset of $1.0\sigma_{y'}$



Conclusions

- The impact of static and dynamic effects has been analyzed and quantified in ATF2. Misalignments, incoming beam angle and position jitters have a large impact on the beam size. The intensity dependence parameter calculated with Placet simulations seems to agree with experimental data.
- The same beam-based correction procedure used in ATF2 gives very good results in the ILC BDS. This procedure decreases the vertical IP beam size to nearly nominal. Therefore, these simulations proved that the intensity-dependent effects of short-range wakefields on the IP beam size are negligible in the ILC BDS.
- Simulations of long-range wakefields due to resistive walls, in a perfect machine, showed that they induce a significant vertical offset at the IP and thus a luminosity degradation in both the 250 and 500 GeV ILC designs. However, one expects that this luminosity loss can be effectively compensated with appropriate IP intra-train feedback.

Thank you